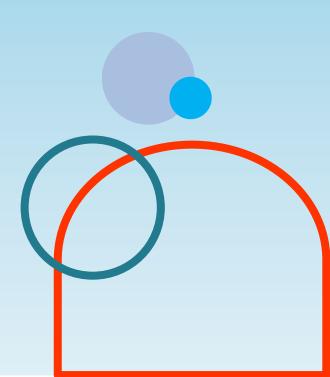


KZK Corporation

Company Profile



As a specialist for silicone materials, KZK Corporation contributes to customer's material development, functional improvement, and other problem solvings through offering new "Si-materials" and application know-how.

What "Si-materials"?

"Si-materials" stands for chemicals or compounds containing silicon(Si) atoms. There are various chemical compositions and forms such as Silanes, Silicones, Silicones, Silicone modified organic materials, etc. These materials are well-known with its unique characteristics and have been used broadly in industries.

KZK Corporation focuses on Si-materials especially "silicon based organic compounds" and develops solutions with Si-materials to improve functions of customers' advanced materials.

Superior Properties of Si-materials

Excellent physical properties

 Heat/cold resistance, , weatherability, transparency, electric characteristics, specific surface characteristics etc.

Essential elements of composite materials

- Silane coupling agents for interface modification for organic/inorganic materials
- Introduction of Si properties and various functional groups to improve performance of organic materials
- Si-containing copolymers, introduction of crosslinking capability

Potential precursor material for inorganic silicon material

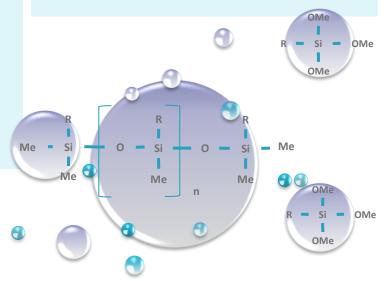
- Silanes for CVD materials
- Formation of thin film inorganic coating by spin coating / baking
- Application to semiconductor process materials, realization of film properties

High flexibility in designing chemical structures

- Control viscosity with main chain length
- Branching, cyclic structure, introduction of organic groups
- · Multiple organic functional groups
- Wide choice on product form, Liquid, elastic material, rigid resin, etc.

Reagents for organic synthesis reactions.

- Polymerization initiators, polymerization co-catalysts
- · Protecting group, carbon-carbon bond forming reagent



Management Policy

- Respond promptly and accurately to social needs through development of Si-materials and strive to improve customer satisfaction.
- Comply with laws and regulations, endeavor to preserve the environment, fulfill our social responsibilities.
- Value human resources and experience, and provide a place for social contribution to employees.

Company Outline

Name: KZK Corporation (ケイ素材料開発株式会社 in Japanese) Address: Yotsuya 4-52-53, Fuchu-shi, Tokyo, 183-0035, JAPAN

TEL: +81-42-136-7268
Capital: JPY5,000,000
Established: October 2013

Chief Executive: Akihiko SHIRAHATA (Ph.D., Technology)



Develop solutions with Si-materials

Various consultation on Si-materials and application know-how New Si-material development to realize customers' requirements

Develop supply chains for Si-materials
 In-house production for key raw materials/intermediates

Contract manufacturing for large scale production
 Support to build stable supply for Si-materials
 Support stable procurement of raw materials and intermediates

History

- **2013** Experienced and knowledgeable members established KZK corporation and started providing products and applications know-how.
- **2014** Established a chemical laboratory in "Nokodai^(*1) Tama Koganei Venture Port ^(*2)". Started experimental trials and material developments. Started joint development works with Nokodai. ^(*1) Nokodai stands for Tokyo University of Agriculture and Technology. ^(*2) VP is a incubation facility under support by government, Nokodai and city.
- **2014** Installed various analytical equipment. Installed small to medium scale production capabilities to respond to the demands in domestic and foreign users
- **2015** Started commercial supply for key, high performance Si-materials. Build domestic and overseas networks to obtain information on raw materials.
- **2016** Continuing investment in analytical equipment under the support of the government fund
- **2017** Strengthening basic research on silicon chemistry with professor Mitsuo Kira (Prof. Silicone chemistry, Tohoku University)
- **2018** Conducted joint research with Professor Toshio Watanabe of Tokyo University of Agriculture and Technology. Established a base of operations at URAC (*3) in April. (*3) University Research Administration Center
- **2014 2021** Implemented technology and product development, adopted by the Small and Medium Enterprise Agency, Tokyo Metropolitan Government, and other subsidized projects.
- **2021** In order to respond to expand businesses, Fuchu Laboratory was newly established (4-52-53 Yotsuya, Fuchu City) to strengthen development activities.

